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A novel and facile synthesis of visible photoluminescence Si nanocrystals by room temperature mechanochemical disproportionation of SiO

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Visible photoluminescence Si nanocrystals (Si NCs) are synthesized *via* a novel and facile room temperature mechanochemical disproportionation of SiO. The size of the synthesized Si NCs can be easily tuned by the mechanochemical conditions. Surface passivated Si NCs exhibit excitation wavelength-dependent photoluminescence, which is attributed to quantum confinement effects.

Si nanocrystals (NCs) have attracted much attention as promising materials for optoelectronic devices, photovoltaics, and *in vivo* bio-imaging based on their broadly size-tunable bandgap due to quantum confinement effects, natural abundance, non-toxicity and good biodegradability.^{1–16} As for optoelectronic devices, Maier-Flaig *et al.*³ and Xin *et al.*⁴ developed Si NC light-emitting diodes giving electroluminescence in red and white–blue wavelengths, respectively, whose research provides a new opportunity for next-generation solid-state lighting and large-area display technology. Tan and Ni *et al.*⁵ developed broadband (from the ultraviolet to near-infrared region) optoelectronic synaptic devices by utilizing Si NCs that can help advance neuromorphic computing. In the case of photovoltaic applications, Kim *et al.* reported highly efficient Si NC heterojunction solar cells recently.⁶ Meinardi *et al.* reported Si NC based highly efficient luminescent solar concentrators, and their flexible device with comparable performance to flat concentrators provides new design freedom for building integrated photovoltaic elements.⁷ By applying boron-doped Si NCs, Ni and Ma *et al.* fabricated graphene-based hybrid phototransistors and obtained remarkable high sensitivity ultra-broadband (from ultraviolet to mid-infrared region) photodetection by taking advantage of the localized surface plasmon resonance of boron-doped Si NCs.⁸ Numerous syntheses of photoluminescent Si NCs have been reported, which can be divided into top-down and bottom-up approaches. In the case of top-down approaches, laser ablation of Si wafer,⁹ electrochemical etching of Si¹⁰ and mechanochemical ball-

milling of bulk Si¹¹ have been demonstrated. As for bottom-up approaches, Si NCs have been synthesized *via* the plasma decomposition of silane,¹² chemical reduction of tetrachloride silane,¹³ thermal pyrolysis of hydrogen silsesquioxane,¹⁴ and thermal disproportionation of SiO_x (1 < x < 2).¹⁵

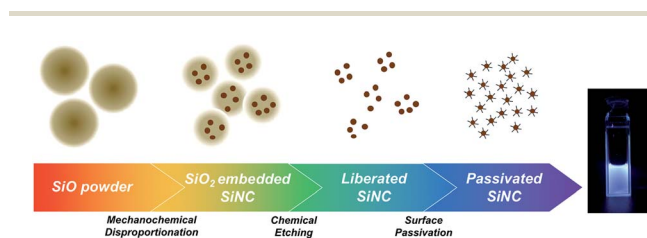
SiO, an amorphous monoxide material, has been widely utilized in electronic devices, such as in anode materials for lithium ion batteries, insulating layers in integrated circuits, *etc.*¹⁶ And as a commercially available material, SiO is also utilized as a promising precursor for Si NC synthesis through thermal disproportionation reactions. Rybaltovskiy *et al.* previously reported the synthesis of Si/SiO_x core/shell nanoparticles by thermal disproportionation of SiO.¹⁷ Sun *et al.* reported the synthesis of free-standing Si NCs on a large-scale, based on thermal disproportionation of SiO.¹⁸ However, both of these synthesized Si/SiO_x core/shell nanoparticles and Si NCs perform photoluminescence in the infrared wavelength region. Also, high temperatures of more than 900 °C are required for the synthesis of Si NCs *via* the thermal disproportionation reaction of SiO. Furthermore, the size of Si NCs must be tuned through critical temperature increasing.^{17–20} In this work, we reported a novel and facile route for the synthesis of visible photoluminescence Si NCs *via* mechanochemical disproportionation of SiO under room temperature. The size of synthesized Si NCs can be easily tuned in the 2–5 nm order by the mechanochemical conditions. After efficient surface passivation, our synthesized Si NCs exhibit visible photoluminescence with a maximum emission peak around 450 nm. Excitation wavelength-dependent photoluminescence behaviour is confirmed, which suggests that the photoluminescence mechanism is attributed to the size dependent wide bandgap in synthesized Si NCs based on quantum confinement effects. To the best of our knowledge, this is the first report of the synthesis of visible photoluminescence Si NCs *via* a low-temperature disproportionation reaction system. In addition, the reaction mechanism of mechanochemical disproportionation was also investigated.

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Si NCs were prepared by mechanochemical ball-milling of 3 g SiO (Osaka Titanium Technology, Co. Ltd) with 40 g ZrO₂ ball under an argon atmosphere. The size of the ZrO₂ ball utilized in this study is 15 mm and the milling duration was settled as 1, 3 and 5 hours, respectively. Free-standing Si NCs were liberated *via* chemical etching of 50 mg mechanochemical disproportionation product by a mixture of hydrofluoric acid (HF, 49%, 3 ml)/hydrochloric acid (37%, 75 μl)/ethanol (0.75 ml). The reaction was conducted in the dark (to maintain the size of Si NCs) for 5 hours in a PTFE container. The Si NCs after chemical etching were extracted by 30 ml toluene solvent twice and collected *via* centrifugation at 9000 rpm for 20 minutes. The surface of the Si NCs was passivated by 1-decene after chemical etching by HF solution to increase the stability and optical properties of the Si NCs. 10 ml 1-decene was added into etched Si NCs and the solution was heated up to 165 °C under an argon atmosphere. After reacting for 13 hours, the solution was mixed with 20 ml methanol/ethanol (1 : 3) solution to remove the excess 1-decene *via* high-speed centrifugation (20 000g, 20 minutes). Si NCs were collected and purified *via* an anti-solvent/solvent system by using methanol/toluene with volume ratio of 3 : 1 for three cycles, assisted *via* high-speed centrifugation (20 000g, 20 minutes for each cycle). Finally, pure and clean toluene was added to the Si NCs, whose solution was filtered through a PTFE membrane with pore size of 200 nm, and then the Si NC solution was ready for further characterizations. The synthesis procedure in this study is summarized in Scheme 1.

The crystal structures of SiO raw powder and mechanochemically treated powders were analyzed by X-ray diffraction (XRD) measurement (Rigaku). The XRD measurement is carried out by Cu K α radiation with an acceleration voltage and current of 40 kV and 40 mA. The chemical structure was also characterized by Raman spectroscopy (Renishaw) with a 532 nm laser. The chemical states of the SiO raw powder and mechanochemically treated powder were investigated by X-ray photoelectron spectrometry (XPS; M-probe SSX-100, S.S.I, USA) with Al K α X-ray ($h\nu = 1486.6$ eV) radiation. The shift of the binding energy due to relative surface charge was corrected using the Au4f level at 83.98 eV. The size and morphology of the Si NCs were confirmed by transmission electron microscopy (TEM, JEOL, JEM-2100F). The photoluminescence spectrum of surface-passivated Si NCs as a toluene dispersion was recorded on a fluorescence spectrometer (JASCO), and the surface and size were confirmed by Fourier transform infrared spectroscopy (FTIR; JASCO) and a dynamic light scattering (DLS; Zetasizer, Malvern) system.



Scheme 1 Synthesis procedure of Si NCs (photograph: emissive Si NCs).

Fig. 1 shows the XRD patterns of raw and mechanochemically treated SiO powders. As for the SiO raw powder, only a halo peak at 21° according to the amorphous component is observed. In the case of mechanochemically treated SiO powder, three sharp peaks appear at 28°, 47° and 56°, corresponding to (111), (220) and (311) planes of crystalline Si.^{2,14–20} According to the Scherrer formula, the size of the crystalline Si domain is increased as the mechanochemical treatment proceeds. We suggest that the crystalline Si is generated through the disproportionation of SiO. Fig. 1b illustrates the Raman spectra of raw and mechanochemically treated SiO powders. For raw SiO, a wide peak at 475 cm⁻¹ corresponding to amorphous Si is observed, whose peak intensity degraded for SiO after mechanochemical treatment. Additionally, a crystalline Si peak appeared in mechanochemically treated SiO and its Raman shift is red-shifted through treatment processing, which demonstrates that the size of the crystalline Si domain increases.¹⁷ Such results from Raman spectra show good agreement with XRD results.

In order to confirm the morphology of the crystalline Si domain in the product, TEM measurement was conducted on the samples. As the images in Fig. 2 show, the raw powder of SiO shows amorphous phase, while Si NCs appear in the amorphous phase after mechanochemical treatment. The lattice fringe with a *d*-spacing of 1.9 Å is observed, which can be assigned as the (220) plane of crystalline Si.^{14–20} The sizes of Si NCs observed for 1, 3 and 5 hours mechanochemical treatment are about 2, 3 and 5 nm. These sizes of Si NCs increased as the mechanochemical treatment time increased, and these results show good agreement with the XRD results given in Fig. 1.

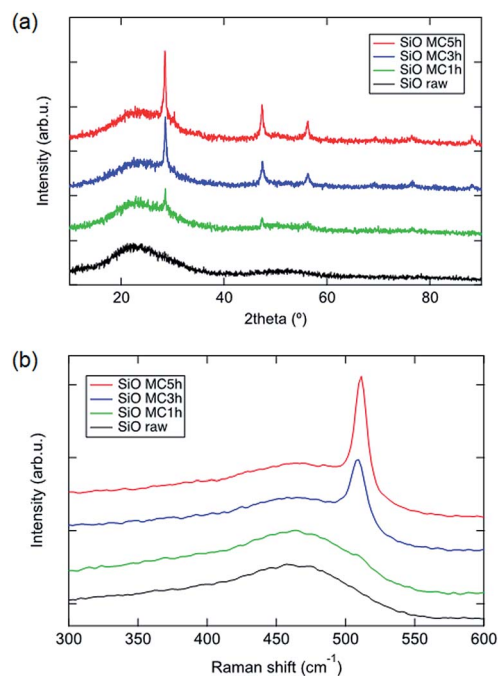


Fig. 1 The XRD patterns (a) and Raman spectra (b) of raw and mechanochemically treated SiO.



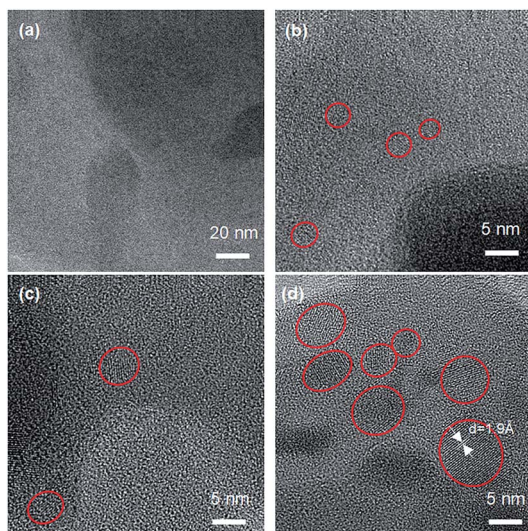


Fig. 2 TEM images of raw (a) and mechanochemically treated SiO for different durations of (b) 1 hour, (c) 3 hours and (d) 5 hours.

To investigate the reaction mechanism of this room temperature mechanochemical disproportionation, the chemical state of Si was analysed by XPS measurement. Fig. 3 demonstrates the XPS spectra of the Si 2p orbital for raw and mechanochemically treated SiO. The spectra are fitted as five peaks at 99.7, 100.6, 101.6, 102.7 and 103.8 eV by Gaussian equations, corresponding to Si^0 , Si^+ , Si^{2+} , Si^{3+} and Si^{4+} states, respectively.^{21,22} The calculated peak area of each component is summarized as the insets of Fig. 3, which illustrate that the amount of Si^0 and Si^{4+} states increased with a decrease of low covalent states like Si^+ and Si^{2+} and Si^{3+} after mechanochemical

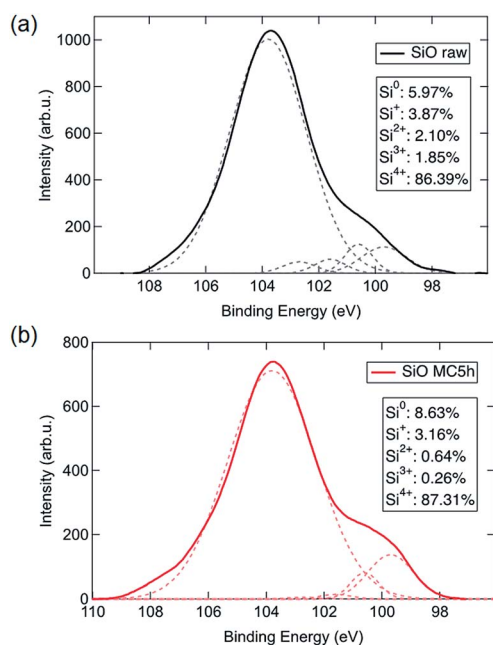


Fig. 3 XPS spectra of the Si 2p orbital of raw and mechanochemically treated SiO.

treatment. These results suggest that a disproportionation reaction on SiO occurs during room temperature mechanochemical treatment and Si NCs in a SiO_2 matrix are generated.

Regarding to XRD, Raman, TEM and XPS results, here we explain the mechanism for the formation of Si NCs as the following three steps. Firstly, Si radicals and Si oxide radicals are generated by the application of mechanical stress during the high-energy planetary ball-milling, whose process should be similar to mechanochemical processing of quartz compounds.²³ The generation of radicals has been demonstrated as a main factor for mechanochemical reaction of mixed solid phases.^{24,25} In addition, the generated Si radicals are stable in the inert atmosphere of argon gas. Secondly, the generated small amount of Si radicals may diffuse through the concentrated SiO matrix based on the Gorsky effect. Such a diffusion mechanism is widely utilized in the mechanochemical synthesis of alloy compounds. Thirdly, Si NC domains are formed by the gathering of Si radicals.^{24,25} The above-described three-step reaction occurs continuously during ball-milling and it can also well explain the growth of the NC size by increasing the milling time.

Next, free-standing Si NCs are liberated *via* HF chemical etching of SiO_2 , and then the surface of the NC is passivated by hydrocarbon solvent to ensure the stability and solubility in organic solvent.^{26,27} Fig. 4 displays the photoluminescence spectra of Si NCs observed from 5 hours mechanochemically treated SiO. Visible emission with wavelength ranges from 400 nm to 600 nm is observed with a strong emission peak at 450 nm. The emission peak is red-shifted as the excitation wavelength red-shifts, and this phenomenon is attributed to the size-tuned bandgaps of the observed Si NCs based on the quantum confinement effect.¹ As the photograph of emissive Si NCs in Scheme 1 shows, a bright blue colour is observed when excited by a UV light source. To confirm the photoluminescence mechanism, the surface state of the passivated Si NCs is measured by ATR-FTIR. According to the ATR-FTIR spectra shown in Fig. 5a, the peaks of C–H stretching around 2900 cm^{-1} , C–H scissoring and methyl rock around 1470 cm^{-1} , long-chain methyl rock at 723 cm^{-1} without any existence of Si–O–Si stretching at 1100 cm^{-1} and Si–H stretching at 2100 cm^{-1} demonstrate that the surface of Si NCs is completely passivated with 1-decene without any oxidation. By referring to several

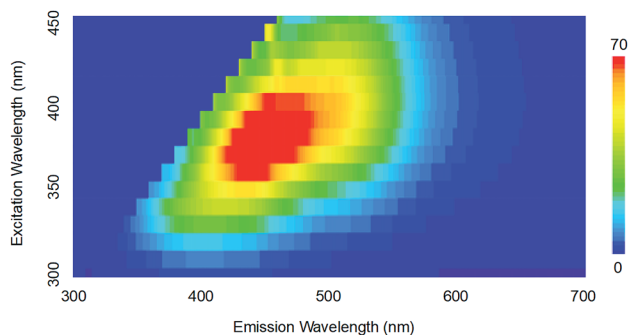


Fig. 4 The 3D photoluminescence spectra of Si NCs under different excitation wavelengths (color bar: photoluminescence intensity).



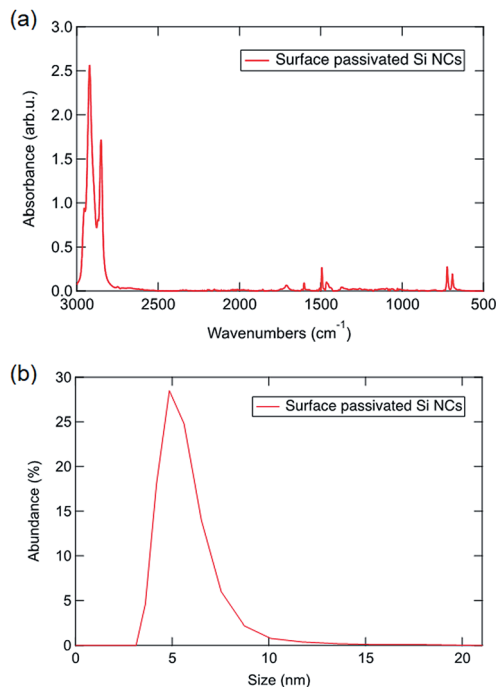


Fig. 5 FTIR spectra and DLS size distribution for surface passivated Si NCs.

experimental and theoretical studies of photoluminescence mechanisms for alkyl-passivated Si NCs,^{28,29} we conclude that the excitation-wavelength-dependent photoluminescence of our Si NCs must be attributed to the electron and hole recombination of the size-dependent direct-like bandgap of core state due to quantum confinement effects, where the wavefunctions of electron and hole are modified through surface passivation by alkyl groups. Additionally, the size distribution of surface passivated Si NCs in solution is evaluated by DLS. As is shown in Fig. 5b, the hydrodynamic size of Si NCs is 5.45 ± 1.39 nm, and this value shows good agreement with the TEM result.

Conclusions

In conclusion, visible photoluminescence Si NCs are successfully synthesized *via* a novel and facile room temperature mechanochemical disproportionation of SiO. The size of Si NCs can be tuned by the mechanochemical treatment time, where the Si NC size increases as the treatment time increases based on the results of XRD and TEM characterizations. Based on the XPS analysis and calculating the component of each chemical state of Si, the disproportionation reaction is confirmed. The synthesized Si NCs exhibit bright blue emission with an excitation wavelength dependent photoluminescence in the visible region. Compared with the conventional thermal disproportionation method, the synthesis process through a room temperature mechanochemical process and easy size-tuning in this paper opens a new strategy for the synthesis of Si NCs. In addition, the Si NCs synthesized in the current work perform visible photoluminescence through the electron and hole recombination between the quantum confined wide bandgap of

the core state, while the Si NCs obtained from thermal disproportionation only show photoluminescence in the infrared wavelength region. This strategy is also expected to be available for the synthesis of other functional NCs like Ge NCs and Sn NCs through such room temperature mechanochemical disproportionation of GeO and SnO.

Conflicts of interest

There are no conflicts to declare.

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